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	Application No.	Applicant(s)	
N. C. C.A.H. C. L. C.A.	09/909,277	GALE ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Gentle E. Winter	1746	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	6 (OR REMAINS) CLOSED in this ap b) or other appropriate communication RIGHTS. This application is subject t	oplication. If not included n will be mailed in due course. TH	IIS tiative
1. This communication is responsive to <u>04/20/04</u> .			
2. The allowed claim(s) is/are 1,3-23 and 25-34 (renumbered	<u>1 as 1-32)</u> .		
3. The drawings filed on are accepted by the Examine	er.		
 4. Acknowledgment is made of a claim for foreign priority unexpected as a claim for foreign priority documents have a claim foreign priority documents have a claim for foreign priority documents have a claim for foreign priority documents have a claim foreign priority documents have a claim for foreign priority documents have a claim for foreign priority documents have a claim fore	e been received. e been received in Application No		ı e
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply MENT of this application.	complying with the requirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXAMINER res reason(s) why the oath or declara	t'S AMENDMENT or NOTICE OF ation is deficient.	
 CORRECTED DRAWINGS (as "replacement sheets") mu (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in 18 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 	son's Patent Drawing Review (PTO 's Amendment / Comment or in the C 1.84(c)) should be written on the drawi the header according to 37 CFR 1.121(poit of BIOLOGICAL MATERIAL r	Office action of ings in the front (not the back) of (d).	
	FOR THE DEPOSIT OF BIOLOGIC	AL MATERIAL.	
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal F	Patent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ⊠ Interview Summary	(PTO-413),	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	Paper No./Mail Da 08), 7. ⊠ Examiner's Amendr		
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's Stateme	ent of Reasons for Allowance	
of Biological Material	9. Other		

DETAILED ACTION

Claim Rejections - 35 USC § 112--Withdrawn

Applicant sought clarification of 112 first paragraph rejection and suggested that support for the claim language could be found in the first lines of page 4 of the specification, but that in an effort to expedite prosecution applicant would acquiesce to the amendment, changing the language.

EXAMINER'S AMENDMENT

- 1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- 2. Authorization for this examiner's amendment was given in a telephone interview with John A. Evans on 4/29/04. Dr. Evans faxed a copy of the authorized amendments. Winter indicated that closed claim language was required and read the below proposed changes to Dr. Evans, Dr Evans indicated that the changes were acceptable.
- 3. The application has been amended as follows:
- 4. In claim 1 now reads:
- 1. (Currently amended) A method for removing contaminants from the surface of a semiconductor substrate comprising:

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forming an intact and contiguous film of a fluid to on a surface of said semiconductor substrate at an ambient temperature;

lowering the temperature of the fluid, thereby forming a solid layer of the fluid over the surface and entrapping contaminants within the layer; and

applying energy consisting of sonic energy having a frequency of from about 5 Hz up to megasonic values to the layer or substrate or both under such conditions as to result in separation of said solid layer including the contaminants from the surface.

5. Claim 23 now reads:

23. (Currently amended) A method for removing contaminants from the surface of a semiconductor substrate comprising:

forming an intact and contiguous film of a fluid on a surface of said semiconductor substrate at an ambient temperature;

lowering the temperature of the fluid by reducing the temperature of the substrate so as to form a solid layer of the fluid over the surface and entrapping contaminants within the layer; and

applying a sonic energy energy consisting of sonic energy having a frequency of from about 5 Hz up to megasonic values to the layer or substrate or both under such conditions as to result in separation of said solid layer including the contaminants from the surface.

Reasons for Allowance

- 6. Claims 1,3-23 and 25-34, renumbered as 1-32 are allowable.
- 7. The following is an examiner's statement of reasons for allowance:

semiconductor.

8. The prior art of record relating to an automotive rearview mirror is not longer applicable because the claims recite a semiconductor wafer, and while the cleaning may be inherent (the invention is concerned with removing ice), the rearview mirror is not generally accepted to be a

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- 9. The prior art of record disclosing the application of water, freezing the water film and then heating the wafer, is distinguished by the reference to: "forming a solid layer...applying energy...separation of *said* solid layer". The claims have been amended to further clarify that the layer is not melted, as is disclosed in the prior art of record.
- 10. The claims further disclose an "intact and contiguous" film. The prior art of record discloses spraying atomized water onto a frozen substrate. Figure 2 clearly indicates that the atomized water coalesces, and the specification speaks to removing particles, not a film.
- 11. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Examiner Winter would like to thank Applicants' representative Dr. John Evans for his professionalism and courtesy.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gentle E. Winter whose telephone number is (571) 272-1310. The examiner can normally be reached on Monday-Friday 7:00-3:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Randy P. Gulakowski can be reached on (571) 272-1302. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Questions on access to the Private PAIR system, should be directed to the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Gentle E. Winter Examiner Art Unit 1746

April 29, 2004

RANDY GULAKOWSKI SUPERVISORY PATENT EXAMINED TECHNOLOGY CENTER 1700